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000	,0.0.0			Application Number	10/602,716-Conf. #9955	
IN	FORMATIO	ON DISC	CLOSURE	Filing Date	June 25, 2003	
STATEMENT BY APPLICANT				First Named Inventor	Chandra Mouli	
_				Art Unit	2811	
	(Use as many	sheets as ne	cessary)	Examiner Name	D. Kang	
Sheet	· 1	of	1	Attorney Docket Number	M4065.0904/P904	

U.S. PATENT DOCUMENTS							
Examiner Initials*	Cite No.1	Document Number Number-Kind Code ² (if known)	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Cotumns, Lines, Where Relevant Passages or Relevant Figures Appear		
0h_	AA	2002/0190287	12/19/2002	Mann et al.			

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Examiner Initials*	Cite No.1	Foreign Patent Document Country Code ³ (If known)	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear	T⁰				
nn	BA	EP 0 798 785	10/01/1997							
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		NON PATENT LITERATURE DOCUMENTS			
Examiner Initials	r Cite No. 1 Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the ite magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publish and/or country where published.		T ²		
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